

IN THE DRAWINGS:

Please amend Figures 1, 2 and 6 as shown on the attached sheets, including formal replacement sheets and annotated sheets showing the changes made. In Figure 1 several terms are replaced with other terms having similar meaning, but which constitute more idiomatic English. In Figure 2, “near infrared” is replaced with --- NIR ---. In Figure 3 “Secondary-differential” is replaced with --- Second differential --- and --- Value of difference spectrum --- is added as a definition of the values indicated at the right vertical side of the chart.

REMARKS

Upon entry of the present Preliminary Amendment-A the claims in the application remain claims 1-4, of which claim 1 is independent.

Several terms and phrases in the title, specification, claims, drawings and abstract are amended by replacement with alternative terms and phrases having corresponding meaning, but which constitute a more accurate translation of International Application PCT/JP2005/003517 and constitute more idiomatic English. Again, in Figure 1 several terms are replaced with other terms having similar meaning, but which constitute more idiomatic English. In Figure 2, “near infrared” is replaced with --- NIR ---. In Figure 3 “Secondary-differential” is replaced with --- Second differential --- and --- Value of difference spectrum --- is added as a definition of the values indicated at the right vertical side of the chart.

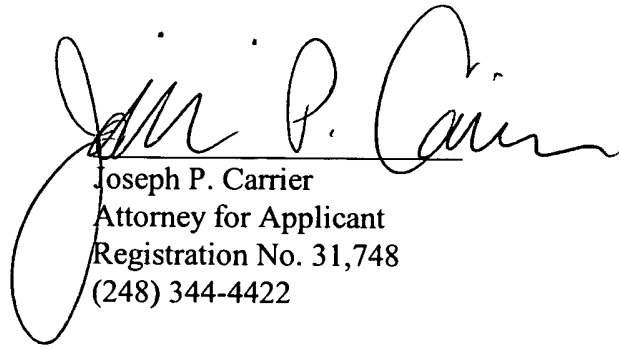
The amendments to the title, specification, and abstract are incorporated in a substitute specification being filed concurrently herewith. Pursuant to 37 CFR 1.125, applicant encloses herewith a clean version of the substitute specification, a marked up copy of the specification showing the changes made thereto, and a verified statement by the undersigned attorney attesting to the fact that no new matter is introduced by the substitute specification.

Applicant respectfully submits that all of the above amendments are fully supported by the original application. Applicant also respectfully submits that the above amendments do not introduce any new matter into the application.

Favorable consideration is respectfully requested.

Respectfully submitted,

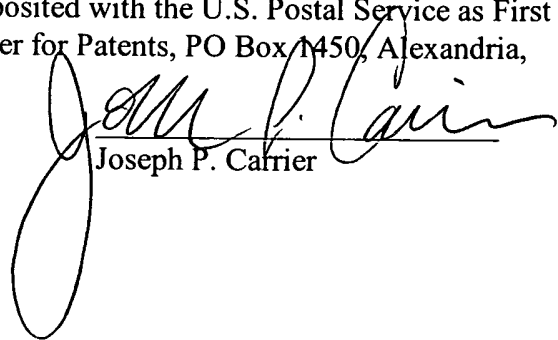
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CERTIFICATE OF MAILING

I hereby certify that this correspondence is being deposited with the U.S. Postal Service as First Class Mail in an envelope addressed to Commissioner for Patents, PO Box 1450, Alexandria, VA 22313-1450 on October 18, 2006.



Joseph P. Carrier

KNJ-235-A

METHOD FOR ~~LEVELING~~ STANDARDIZING SYSTEM RESPONSE

CHARACTERISTICS ~~OF SPECTROSCOPE~~ SPECTROPHOTOMETER

DESCRIPTION

Cross-reference To Related Applications

[000.1] _____ The present application is the US National Phase of International Application PCT/JP2005/003517, which in turn claims convention priority from Japanese patent application 2004-058443, filed 03 March 2004. The entire disclosures of the referenced International and Japanese priority documents are incorporated herein by reference.

Technical Field

[0001] The present invention relates to a method for ~~leveling a spectroscop~~standardizing system response characteristic ~~for correcting of a spectrophotometer in order to correct the difference between spectroscop~~response characteristics ~~between spectroscopic differences generated due to the difference between in response characteristics of a light source, spectrograph wavelength selector, and sensor.~~

Background Art

[0002] To control measurement errors and fluctuations ~~of generated by a plurality of inspection instruments for mass in large scale production of products, it the adjustment to fit each instrument is frequently performed to adjust each inspection instrument by using an exclusive jig tool.~~ However, ~~in the case of calibration of when~~

many check points are present to calibrate the inspection instruments, lots of work times and predetermined man-hours are required when many check points are present and finally, the adjustment cost greatly influences a product price. Therefore, it is preferable to minimize the number of check points requiring adjustment to calibrate the instrument. However, in the case of a product for which accuracy of inspection instrument is requested, artifice is necessary.

[0003] For example, Patent Document 1 describes the following expression as a ~~relative relational expression for showing the correlation~~relationship between the ~~measured value and the true value of a reproduced signal on an optical disk and the measured signal produced by an optical disk inspection instrument~~ in order to reproduce an optical disk ~~to be inspected by an optical disk with similar signal using multi-inspection instruments.~~

True value Y_i = Gain correction coefficient a_j × measured value X_i + offset
correction coefficient b_i (a)

X_i : Measured value of reproduced signal

Y_i : True value of reproduced signal

a_j : Gain correction coefficient for correcting gain for each interval

b_j : Offset correction coefficient for correcting offset for each interval

~~Moreover, the~~The gain correction coefficient a_j and the offset coefficient b_j are obtained for each interval. ~~Furthermore, Patent Document 1 describes a method for calibrating measurement means~~each optical disk inspection instrument in accordance with ~~[[a-]] the calibrated value~~values obtained by using ~~the computing means and expression (a).~~ Furthermore, Patent Document 1 describes a method for inspecting an optical disk to be inspected ~~is described in Patent Document 1 using calibrated inspection instruments~~

Patent Document 1: Japanese Patent Application Publication No.
2003-1897440

Disclosure Summary of the Invention

[0004] However, when an object to be inspected has a frequency (wavelength) ~~characteristic~~response more complex than that of an optical disk ~~and the reflection, for example,~~ spectrum of an apple is measured in a wavelength range of 700 to 1,100 nm by using, ~~for example,~~ a ~~discrete~~dispersive-type near infrared ~~apparatus~~instrument, there is a problem that individual difference between objects to be measured is large, ~~which is not present~~ than that presented in an optical disk.

Though the approximate expression (a) shown in Patent Document 1 is used, it is impossible to find a proper linear correction parameter as shown by linear correction data in Table 1.

Also when using the following approximate expression (b) using a more-complex polynomial,

$$y = k_0 + k_1s + k_2x^2 \quad (b)$$

it is impossible to find a proper polynomial parameter as shown by the polynomial correction data in Table 1.

[0005]—

[Table 1]

Adjustment line -condition	Calibration method	
	MLR	PLS

	SEP	Bias	SEP	Bias
No adjustment	0.34	-0.42	0.35	-0.53
700-1,100 nm linear correction	0.34	-1.07	0.32	-1.31
700-1,100 nm polynomial correction	0.34	-0.48	0.31	-1.14
850-1,050 nm linear correction	0.34	-0.46	0.32	-1.24
850-1,050 nm polynomial correction	0.34	0.25	0.31	-1.06

(Note 1) Analysis algorithm

MLR (Multiple Linear Regression)

PLS (Partial Least Squares)

(Note 2)

SEP: Residual-error standard error (~~Standard error of bias~~Bias-corrected expected value)standard error of prediction)

Bias: Average of differences between ~~estimated values and chemical analysis~~ actual values according to chemical analysis and estimated values according to near infrared spectroscopy

[0006] Moreover, when moving a calibration model (hereafter referred to as model) for performing quantitative analysis and qualitative analysis by using the near infrared spectroscopy from a unit developing the model to another similar unit, an error occurs due to the difference between ~~spectral-apparatus response~~ characteristics-spectrophotometric system responses. In the case of the quantitative analysis, there is a method referred to as bias correction method of the model as a correction method. However, this method is ~~correction-of~~ to correct an estimated result, which requires correction for each model and labor and whose operation is complicated.

However, the correction method for qualitative analysis is not developed yet.

[0007] It is an object of the present invention to provide a method for leveling response characteristics standardizing system response of a spectroscopespectrophotometer for correcting the distortion of a spectrum generated due to the difference between spectroscopy response characteristics system responses of spectrophotometers so that a model developed by a parentmaster unit can be used by a childslave unit.

To achieve the above object, a method of the present invention for levelingstandardizing the system response characteristic of a spectroscopy provides a method for spectrophotometer involves adjusting the system response characteristic of a childslave unit to the system response characteristic of a parentmaster unit by subtracting the spectrum of a standard substance measured by the parent unit, for example, secondary differential spectrum from the spectrum of the standard substance measured by the child unit, for example, secondary differential spectrum thereby obtaining the difference spectrum between the child unit and the parent unit, and thereby subtracting the difference spectrum from the secondary differential spectrum of each sample to be measured by the child unit, calculating the difference spectrum between the slave unit and the master unit. For example, the difference spectrum may be calculated by subtracting a spectrum of a standard material, for example, a second derivative spectrum, measured by the slave unit, for from a second derivative spectrum of a standard material measured by the master unit. Then the spectrum of each object measured by the slave unit is standardized by subtracting with the calculated difference spectrum. By using the secondary differentialsecond derivative spectrum for calculating the difference spectrum, there is an advantage that thebaseline shift of the base line is eliminated.

[0008] As the spectrum of the standard ~~substance~~material, the spectrum of a sample to be measured, ~~secondary differential~~second derivative spectrum, or average spectrum of ~~the spectrum of the sample and the secondary differential spectrum~~those spectra mentioned before is considered. In the case of the average spectrum, the following two cases are assumed: a case of measuring a plurality of ~~spectrum~~spectra by one sample to be measured and obtaining the average spectrum and a case of measuring a plurality of ~~spectrum~~spectra by a plurality of samples and obtaining the average spectrum.

[0009] An ~~apparatus~~apparatus/instruments to which near infrared spectroscopy is applied is constituted of ~~a beam of light, spectrograph, light source,~~
~~spectrograph~~wavelength selector, and sensor. Wavelength characteristics, ~~luminances~~light intensity, and ~~sensor~~ sensitivities of ~~them~~the spectrophotometer are delicately different for each individual ~~piece~~piece/instrument and the combination of spectroscopy response characteristic which is these responses gives the overall characteristic of the instrument which is apparatus ~~is delicately different for each apparatus. Moreover~~delicately different for each instruments. MoreoverIn addition, a shift of the wavelength of ~~a spectroscopy~~spectroscopy ~~between each spectrophotometer~~ occurs. However, the ~~spectroscopy response characteristic is peculiar to each apparatus~~spectrophotometric system response is peculiarspecific to each apparatus/instrument when a light source, ~~spectrograph~~wavelength selector, and sensor are decided.

[0010] Therefore, because a shift of absorbance value of a ~~child~~slave unit in each wavelength from a ~~parent~~master unit similarly occurs in each sample to be measured, it is possible to correct a spectrum distortion generated due to the difference between ~~spectroscopy response characteristics~~spectrophotometric system responses by subtracting the shift of the absorbance value in each wavelength

from the spectrum of each sample, for example, ~~secondary differential derivative~~ spectrum.

[0011] ~~According to~~ By using the present invention, in the case of a fruit sugar content selector sweetness sorting machine, it is easy to ~~move a sugar content analytical distillation developed by a reference selection line (parent unit)~~ transfer a mathematical model to predict sweetness developed from spectra of a master unit to a plurality of other selection lines ~~(child unit)~~; sweetness sorting units (slave units). By this invention, the difference between lines is eliminated, and the reliability of the selector ~~selector~~ sweetness sorting machine is improved. Moreover, there are advantages that the selector ~~selector~~ sweetness sorting machine is easily maintained and persons are released from the hard work at the job site for correcting the difference between lines: by the conventional bias-correction technique.

Brief Description of the Drawings

[0012] Figure 1 is an illustration showing an example of an apple sugar content selector; sweetness sorting machine;

Figures 2(a) and 2(b) are illustrations showing ~~secondary differential~~ spectrums derivative spectra measured by near infrared ~~apparatuses~~ (near infrared apparatuses NIR) instruments A and B;

Figure 3 is an illustration showing an example of applying a model developed by the ~~near infrared apparatus~~ apparatus NIR instrument A to the spectrum of the ~~near infrared apparatus~~ apparatus NIR instrument B;

Figure 4 is an illustration showing a difference spectrum obtained by subtracting the ~~secondary~~ secondary differential derivative spectrum of an apple

measured by the ~~near-infrared apparatus~~NIR instrument A from that of an apple measured by the ~~near-infrared apparatus~~NIR instrument B;

Figure 5 is an illustration showing an example of applying a model developed by the ~~near-infrared apparatus~~NIR instrument A to the leveling ~~spectrums~~spectrum ~~standardized spectra~~ of the ~~near-infrared apparatus~~NIR instrument B; and

Figure 6 is an illustration showing a difference spectrum obtained by subtracting the average spectrum of ~~secondary-differential spectrums~~ derivative spectra measured by a ~~parent~~parent ~~master~~ unit from the average spectrum of ~~secondary-differential spectrums~~ derivative spectra measured by a ~~child~~child ~~slave~~ unit and the average spectrum of the ~~parent~~parent ~~master~~ unit.

Best Mode for Carrying Out Detailed Description of the Invention

[0013] ~~Best~~A best mode for carrying out the invention is described below. Figure 1 is one of the embodiments of the present invention, which shows an example of an apple ~~sugar-content selector~~sweetness sorting machine. In the case of the ~~selectors~~sweetness sorting machine, a tungsten lamp is used for the light source, a ~~diffraction~~ grating is used for the ~~spectrograph~~wavelength selector, and a diode array detector is used for the sensor.

[0014] At the stage for preparing a model by the ~~parent~~parent ~~master~~ unit in Figure 1(1), a plurality of samples (apples) 1 to be measured are measured by the sensor 2 of the ~~parent~~parent ~~master~~ unit to obtain the ~~secondary-differential spectrum~~ derivative spectrum 3 of the ~~parent~~parent ~~master~~ unit. Then, chemical ~~analysis~~analysis ~~component~~ values 4 of the samples (apples) 1 are obtained. A model 5 is obtained by the chemometrics method such as the multiple regression ~~analysis~~ in

accordance with based on the data for the above secondary-differential derivative spectrum 3 and the above chemical component values 4.

[0015] At the stage for obtaining the difference between spectral characteristics of the parentparentmaster unit and childehildslave unit in Figure 1(2), a plurality of samples (apples) 6 to be measured are measured by the sensor 2 of the parentparentmaster unit to obtain the average spectrum of the secondary-differential spectrums derivative spectra of the parentparentmaster unit. Then, the same samples (apples) 6 to be measured are measured by the sensor 8 of the childehildslave unit to obtain the average spectrum 9 of the secondary-differential spectrums derivative spectra of the childehildslave unit. Moreover, the difference spectrum 10 between secondary-differential values of second derivative values is obtained by subtracting the average spectrum 7 of the parentparentmaster unit from the average spectrum 9 of the childehildslave unit.

At the stage for levelinglevelingstandardizing the spectral characteristics of the childehildslave unit in Figure 1(3), each sample (apple) 11 to be measured is measured by the sensor 8 of the childehildslave unit and the secondary-differential derivative spectrum 12 of the childehildslave unit is measured to obtain a leveledleveledstandardized secondary-differential derivative spectrum 13 obtained by subtracting the difference spectrum 10 from the secondary-differential derivative spectrum 12. By applying the model 5 to the leveledleveledstandardized secondary-differential derivative spectrum 13, a purposed chemical component value 14 is obtained.

[0016] Figure 2 is shows near infrared secondary-differential spectrums derivative spectra of apples (product-classvariety: Fuji) measured by two discretedispersive-type near infrared apparatusesapparatusesinstruments (NIRS6500-made by NIR SystemsNIR- Systems, NIRS6500) (referred to as near-infrared

~~apparatuses~~~~apparatuses~~ NIR instruments A and B). The near infrared ~~apparatus~~~~apparatus~~ instrument uses a tungsten lamp as a light source, a diffraction grating as a ~~spectrograph~~ wavelength selector, and a silicon detector as a sensor.

[0017] The following model of the following expression is developed ~~through~~~~through~~ by multiple regression in accordance with ~~with~~ based on the ~~secondary differential derivative values measured by the NIR instrument A and sugar contents (Brix values) of spectrums of 100 apples, measured by the near infrared apparatus A.~~

$$C = 16.035 - 266.386D2A(906) + 1351.578D2A(870) \quad \dots (1)$$

~~In this case~~ Where, C ~~denotes~~ is a Brix value, and D2A(906) and D2A(870) are ~~secondary differential derivative values of spectrumsspectrumsspectra~~ values of spectrumsspectrumsspectra at 906 nm and 870 nm, respectively.

[0018] Figure 3 shows results of applying the model of the above expression (1) to a spectrum measured by the ~~near infrared apparatus~~~~apparatus~~ NIR instrument B. In this case, it is found that a negative bias of -0.42° Brix is generated.

[0019] Figure 4 is a difference spectrum obtained by subtracting the average spectrum of ~~the near infrared apparatus A from the average spectrum of~~ secondary differential spectrums second derivative spectra of the above 100 apples ~~measured by the near infrared apparatus~~~~apparatus~~ NIR instrument A from the average spectrum of secondary differential spectrums derivative spectra of the above 100 ~~applessame samples measured by the near infrared apparatus~~~~apparatus~~ NIR instrument B. Figure 4 shows the wavelength range of 860 to 910 nm to be used for the model. It is found that the ~~secondary differential derivative value of the near infrared~~

~~apparatus~~NIR instrument B is slightly larger than that of the ~~near infrared~~NIR instrument A in the wavelength region. At 906 nm, the ~~secondary differential derivative~~ value is ~~large~~larger by 0.0021515 and at 870 nm, the value is large by 0.0008103. Therefore, when assuming that the ~~secondary differential derivative~~ values at 906 nm and 870 nm of the ~~near infrared~~NIR instrument B are $D2A(906)_B$ and $D2A(870)_B$, respectively, a corrected value is obtained from the following expression.

$$D2A(906) = D2A(906)_B - 0.0021515$$

$$D2A(870) = D2A(870)_B - 0.0008103 \quad \dots (2)$$

By substituting the value of expression (2) for the model of expression (1), it is possible to apply the model developed by the ~~near infrared~~NIR instrument A to the spectrum measured by the ~~near infrared~~NIR instrument B.

[0020] Figure 5 shows results of correcting and recalculating the data shown in Figure 3 by the above described method. A bias becomes 0.05° Brix and occurrence of errors produced due to the difference between ~~spectroscopy response characteristics~~system responses of spectrophotometers is almost cancelled. This improvement degree is clear as a result of comparing with calibration result data of linear correction and polynomial ~~expression~~ correction in Table 1.

[0021] Figure 6 shows a difference spectrum obtained by subtracting the average spectrum of ~~secondary differential spectra~~ derivative spectra measured by the ~~parent~~master unit from the average spectrum of ~~secondary differential spectrum~~ derivative spectra measured by the ~~child~~slave unit and the average spectrum of the ~~parent~~master unit in a wavelength region of 850 to 1,050 nm together. When assuming a difference spectrum as $\Delta A(\lambda)$ and a ~~secondary differential derivative~~

spectrum of ~~each~~ a sample measured by the ~~child~~~~child~~~~slave~~ unit as $S_B(\lambda)$, a ~~leveled~~~~leveled~~~~standardized~~ secondary differential derivative spectrum $S_C(\lambda)$ is shown by the following expression.

$$S_C(\lambda) = S_B(\lambda) - \Delta A(\lambda) \quad \dots (3)$$

~~In this case, λ denotes~~Where, λ ~~denotes~~is a wavelength (nm).

Industrial Applicability

[0022] It is possible to apply ~~leveling of the spectroscopy response~~
~~characteristic~~~~characteristic~~~~the standardization method for standardizing of system~~
~~response of spectrophotometer~~ by the present invention to ~~a line for measuring, for~~
~~example, a sweetness sorting machine which measures~~ the spectrum of fruit moved by,
~~for example, a belt conveyer and selecting~~~~selectsing~~ the fruit in accordance with a
~~chemical component value such as an obtained sugar content.~~

[0023] Although there have been described what are the present exemplary
embodiments of the invention, it will be understood that variations and modifications may be
made thereto within the spirit and scope of the appended claims.

ABSTRACT

A method for leveling spectroscopy response characteristics standardizing system response of spectrophotometer which corrects the difference between spectroscopy response characteristics spectrophotometric system responses generated due to the difference between in response characteristics of a light source, spectrometer wavelength selector, and sensor, and involves obtaining the difference spectrum between a parent master unit and a child slave unit relative to a standard substance material and adjusting standardizing the response characteristic of the child slave unit to the response characteristic of the parent master unit by subtracting the difference spectrum from the spectrum of each sample to be measured by the child slave unit. With an apparatus instrument which is constituted of a light source, spectroscopy wavelength selector, and sensor and to which a near-infrared NIR spectroscopy is applied, a shift of an absorbance value in at each wavelength of the child slave unit from the absorbance value of the parent master unit is similarly generated in each sample to be measured. Therefore, by subtracting the shift of the absorbance value at each wavelength from the spectrum of each sample, it is possible to correct the spectrum distortion generated due to the difference between system response characteristics of spectroscopy of spectrophotometer.

FIG. 1

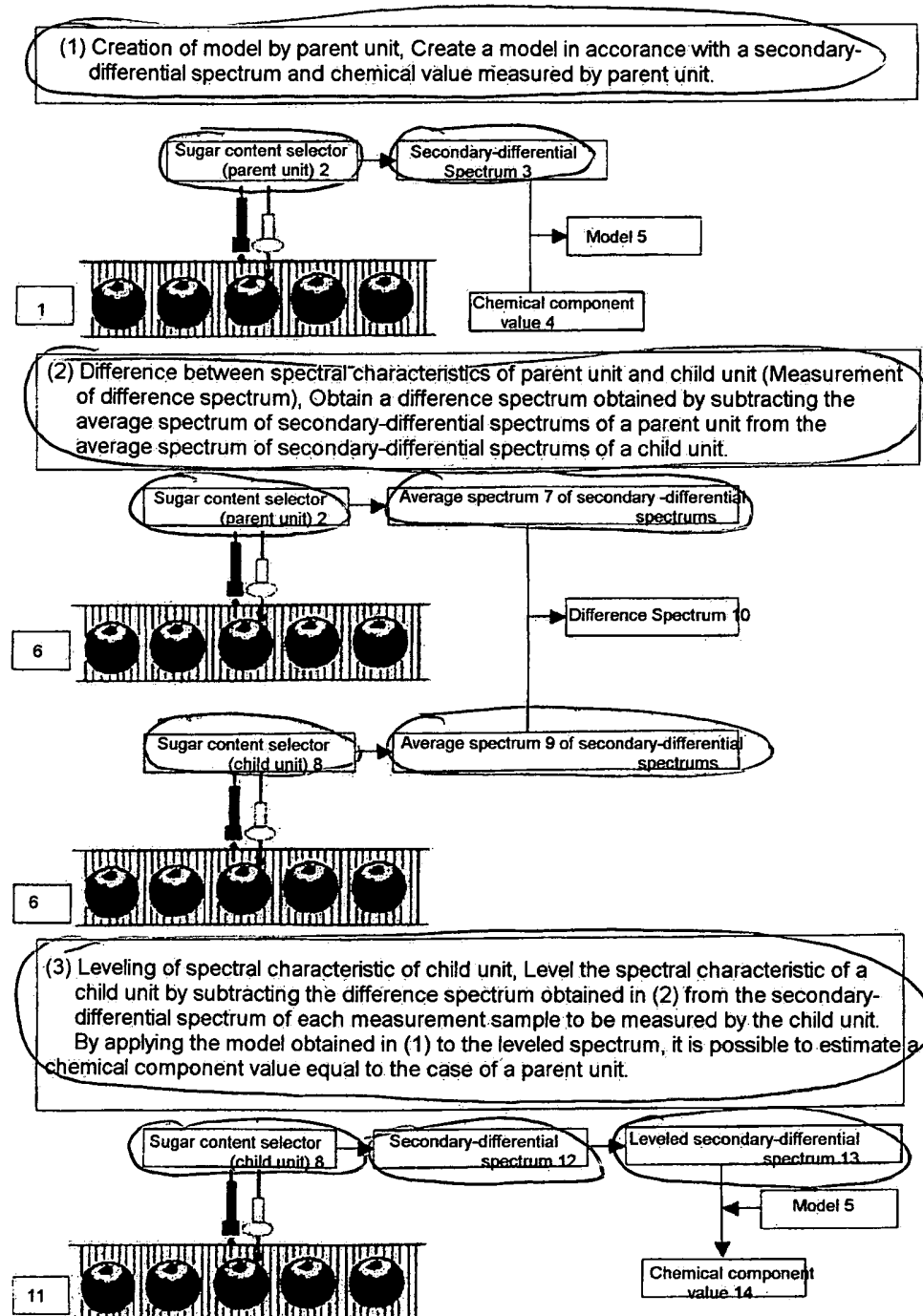


FIG. 2

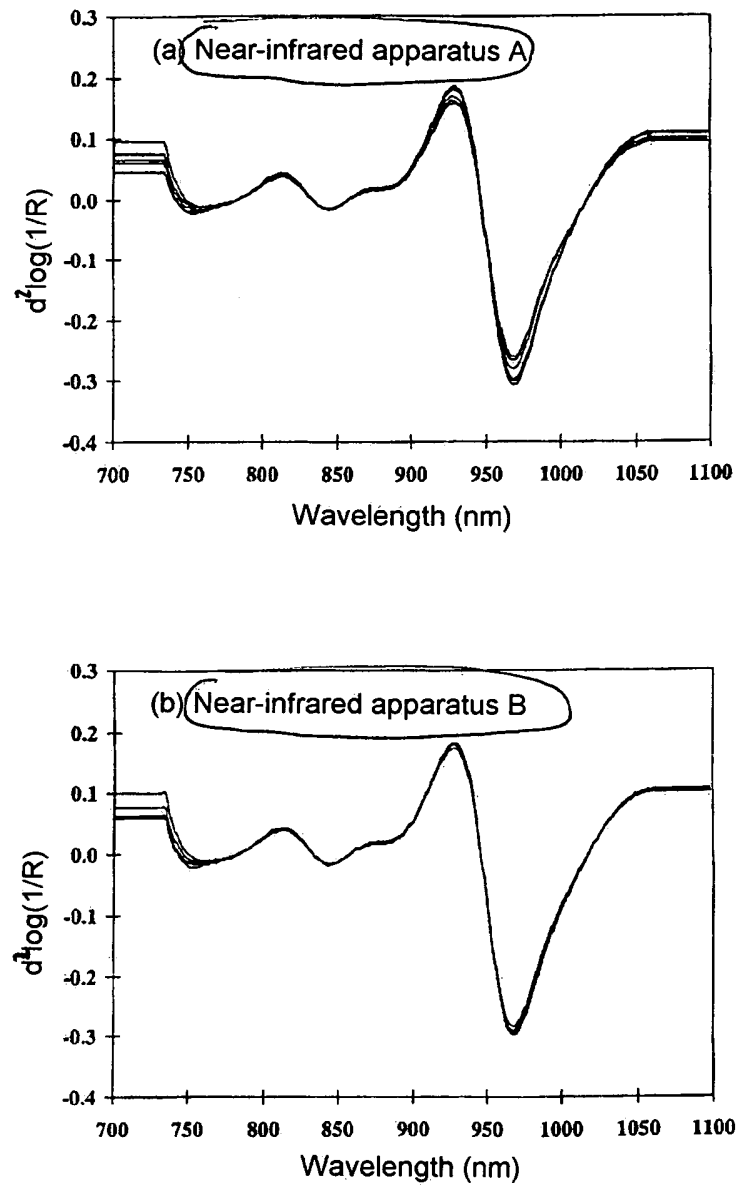


FIG. 3

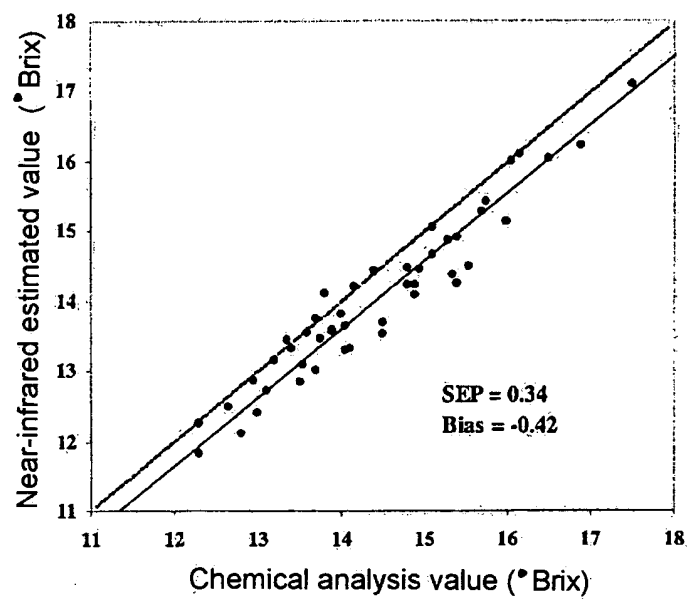


FIG. 4

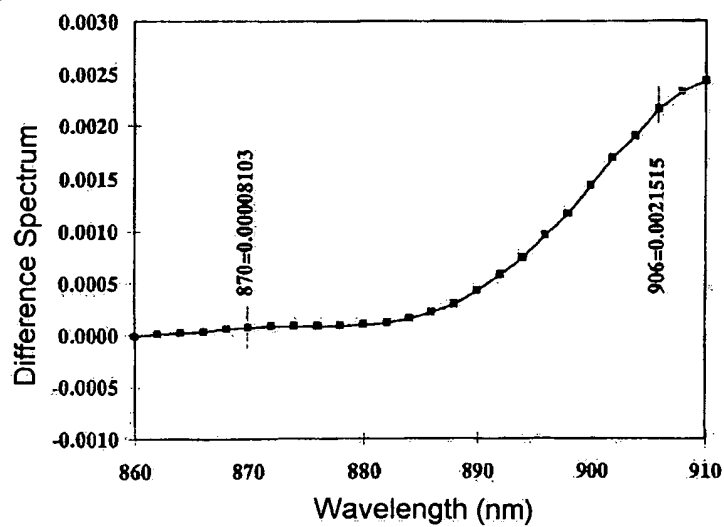


FIG. 5

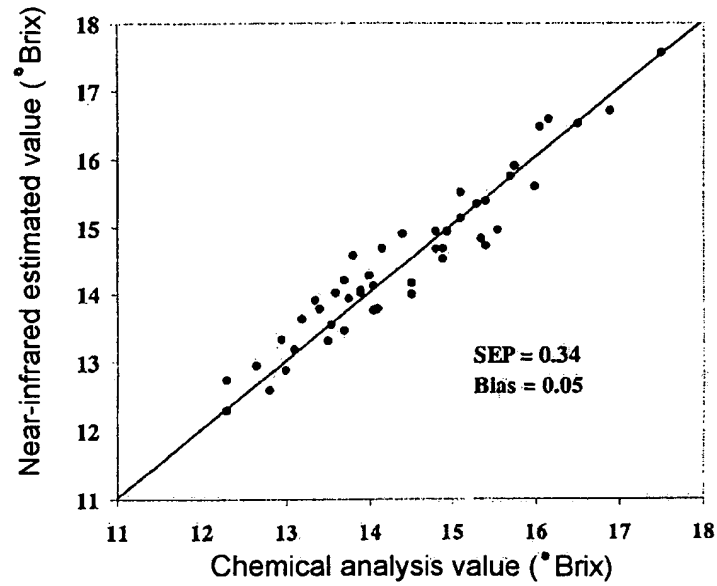


FIG. 6

